

Heubach formulation No. 715-03

08/13

| FUNCTION | PRODUCT | PRODUCER | PBW |
|--|---------------------------------------|-----------------|---------------|
| Polyester | Uralac SH 970 S2E5-40, 40% | DSM | 18.10 |
| Levelling agent | Disparlon L-1984, 50% in Solvesso 150 | Erbslöh | 2.05 |
| Solvent | Solvesso 150 | CG Chemikalien | 4.05 |
| Solvent | Isophorone | | 1.35 |
| Anticorrosive pigment | HEUCOPHOS® SRPP | Heubach | 3.75 |
| Titanium dioxide | Kronos 2160 | Kronos | 5.80 |
| Antisettling agent | Aerosil R 972 | Evonik | 1.80 |
| Grind. | | | |
| Solvent | Solvesso 150 | CG Chemikalien | 6.35 |
| Solvent | Isophorone | | 2.15 |
| Solvent | Diacetone alcohol | | 1.60 |
| Melamine resin | Cymel 303LF, 100% | Allnex | 1.90 |
| Polyester | Uralac SH 970 S2E5-40, 40% | DSM | 48.80 |
| Add while mixing. | | | |
| Epoxy | Epikote 828, 100% | Momentive | 1.05 |
| Solvent | Solvesso 150 | CG Chemikalien | 0.20 |
| Solvent | Isophorone | | 0.05 |
| Mix until uniform solution prior to addition. | | | |
| Catalyst | Nacure 2500 | King Industries | 1.00 |
| Add while mixing. | | | |
| | | | 100.00 |
| SPECIFICATIONS | | | |
| Vol.-% Anticorrosive pigment reg. pigment/filler | | | 35.0 |
| PVC in % | | | 12.5 |
| PVC / CPVC | | | 0.3 |

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